

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: SOO-SUK LEE, ET AL.

FOR: MICROARRAY SUBSTRATE COMPRISING PATTERNED PHOTORESIST
FILM WITH SPOT REGIONS, MICROARRAY, AND METHOD OF
DETECTING TARGET MATERIAL

PRELIMINARY AMENDMENT

Mail Stop Patent Application
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Prior to the Examiner acting in the above-referenced application, please
preliminary amend the above-identified application as follows.